

Low-power high-performance 32-bit RISC-V microcontroller on 65-nm silicon-on-thin-BOX (SOTB)

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Abstract In this paper, a 32-bit RISC-V microcontroller in a 65-nm Silicon-On-Thin-BOX (SOTB) chip is presented. The system is developed based on the VexRiscv Central Processing Unit (CPU) with the Instruction Set Architecture (ISA) extensions of RV32IM. Besides the core processor, the System-on-Chip (SoC) contains 8KB of boot ROM, 64KB of on-chip memory, UART controller, SPI controller, timer, and GPIOs for LEDs and switches. The 8KB of boot ROM has 7KB of hard-code in combinational logics and 1KB of a stack in SRAM. The proposed SoC performs the Dhrystone and Coremark benchmarks with the results of 1.27 DMIPS/MHz and 2.4 Coremark/MHz, respectively. The layout occupies 1.32-mm² of die area, which equivalents to 349,061 of NAND2 gate-counts. The 65-nm SOTB process is chosen not only because of its low-power feature but also because of the back-gate biasing technique that allows us to control the microcontroller to favor the low-power or the high-performance operations. The measurement results show that the highest operating frequency of 156-MHz is achieved at 1.2-V supply voltage (V_{DD}) with +1.6-V back-gate bias voltage (V_{BB}). The best power density of 33.4- μ W/MHz is reached at 0.5-V VDD with +0.8-V VBB. The least current leakage of 3-nA is retrieved at 0.5-V V_{DD} with -2.0-V V_{BB} .

Keywords: 32-bit microcontroller, back-gate bias, RISC-V, RV32IM, Silicon-on-Insulator, SOTB.

Classification: Integrated circuits (memory, logic, analog, RF, sensor)

1. Introduction

From the beginning of the 21st century, the Reduced Instruction Set Computer (RISC) architecture was already dominant in the mobile marketplace because of its low-power and lowcost characteristics [1]. For example, there were RISC-based

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DOI: 10.1587/elex.17.20200282 Received August 19, 2020 Accepted September 4, 2020 Publicized MM DD, YYYY Copyedited MM DD, YYYY Central Processing Units (CPUs) like ARM CPUs in most of the hand-held devices [2], and MIPS-based CPUs in most of the gaming consoles [3]. And very recently, the emerging of the open-source RISC-V Instruction Set Architecture (ISA) was challenging even the most senior Integrated Circuit (IC) design companies. The development of RISC-V was expanding and turning the silicon industry to more efficiently than ever. Comparing to the conventional IC development flow, the RISC-V ecosystem is like "one barbarian is at the gates with a refurbished siege engine" [4].

RISC-V is an open-source ISA that was first presented by the Berkeley architecture group in 2014 [5], and now it is maintaining by the RISC-V Foundation group [6]. The primary goal of the RISC-V Foundation is to provide a completely open ISA to support the research, development, and education in both academia and industry areas. The ISA can support 32-bit, 64-bit, and 128-bit address spaces. It was designed specially to avoid the "over-architecting" in microarchitecture by implementing only the small base integer of ISA [7]. Then based on the bases, the ISA can be extended with many of standard extensions like "M" for multiplication and division, "A" for atomic, "F" for floatingpoint, "D" for double, "C" for compressed instruction sets, and more [7]. Finally, the RISC-V ecosystem is developed, and the toolchains such as assemblers, linkers, compilers, and operating systems are provided by the RISC-V Foundation to suit all of the above standard ISA extensions [8]. As a result, the way of designing and the time for developing a highly customized processor have become much more efficient and robust.

Up to now, there are plenty of RISC-V processors that have been presented in both academic and industrial forums. The IP cores, the System-on-Chips (SoCs), and the development kits were proposed and developed in both Field-Programmable Gate Arrays (FPGAs) and Application-Specific Integrated Circuits (ASICs) [9, 10, 11, 12, 13]. Some worth-mention works are the highly customizable Rocket cores of the Berkeley architecture group [14], the high-performance 32-bit E-core series [15] and 64-bit Ucore series [16] of the SiFive Inc., and the 32-bit RI5CY cores [17] and 64-bit Ariane cores [18] of the PULP-platform research group. For small low-power energy-efficient 32bit RISC-V microprocessors, although there were plenty of IP cores presented in FPGAs as reviewed by R. Höller et al. in June 2019 [19], silicon proof publications were still limited. The worth-mention 32-bit RISC-V chip measurement publications can be listed are the Parallel Ultra-

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Low Power (PULP) SoC in 2016 [20], PULPv2 SoC in 2017 [21], the low-power microcontroller intended for Internet of Things (IoT) in 2016 [22] and 2017 [23], the FE310-G000 in 2017 [24], and the FE310-G002 in 2019 [25].

In this paper, a 32-bit RISC-V microcontroller is presented and measured. The core processor is the VexRiscv CPU [26] with the RV32IM ISA extensions. Then based on the CPU, the completed SoC is built, including 8KB of boot ROM with 1KB of a stack in SRAM and 7KB of hard-code in combinational logics, 64KB of SRAM on-chip memory, UART controller, SPI controller, timer, and GPIOs. The 65-nm Silicon-On-Thin-BOX (SOTB) process was chosen due to its low-power feature [27]. Furthermore, it can provide the chip with the back-gate biasing technique, which allows us to enhance the chip performances further [28]. The chip layout sits on a die area of 1.32-mm², which equivalents to 349,061 of NAND2 gate-counts. The core power supply (V_{DD}) was measured from 0.5-V to 1.2V, and the I/O V_{DD} was fixed at 3.3-V. The peak performance of 156-MHz maximum operating frequency (FMax) was achieved at 1.2-V V_{DD} with +1.6-V of back-gate bias voltage (V_{BB}). The best power density of 33.4- μ W/MHz was reached at 0.5-V V_{DD} with +0.8-V V_{BB}. At sleep mode, when the clock is cut off, the lowest value of 3-nA current leakage was achieved at 0.5-V V_{DD} with –2.0-V V_{BB} . The completed SoC was benchmarked with the Dhrystone and Coremark tests, and the results were 1.27 DMIPS/MHz and 2.4 Coremark/MHz, respectively.

The remainder of this paper is organized as follows. Section 2 describes the architecture of the proposed SoC chip. Section 3 gives details of the measurement results. Finally, Section 4 concludes the paper.

2. Architecture

Fig. 1 shows the proposed architecture of the microcontroller. The core processor is the VexRiscv CPU generated with full options [26], including cache trashing, cache exceptions, single cycle barrel shifter, debug module via JTAG, dynamic branching, and Memory Management Unit (MMU). Comparing to the original design from the SpinalHDL [26], for better fitting in the chip, the caches sizes were increased a little bit to 4.5KB for each of the data and instruction caches.



Fig. 1 The microcontroller architecture.

The SPI controller was added for the usage of the SD-card. The GPIO has 16 LEDs and 16 switches. The 64KB size of the on-chip memory was chosen due to the size limitation of the intended fabricated chip. The 8KB of boot ROM contains 7KB of hard-code in combinational logics and 1KB of a stack in SRAM. The 1KB of SRAM stack can be used later after boot. The 7KB hard-code boot ROM inits the Control/Status Registers (CSRs) in the CPU, prints the initial text to the UART, starts the SD-card, loads the program from the SD-card to the on-chip memory, and jumps to the on-chip memory and executes there. With this boot flow, the microcontroller can self-boot to run any desired software in the SD-card for an embedded application. The source codes and guide for replicating this proposed microcontroller are published in the given repository [29].

3. Evaluation

3.1 Silicon-on-thin-BOX (SOTB)

Fig. 2 shows the structure of the SOTB Complementary Metal Oxide Semiconductor (CMOS) with the triple wells of deep N-well, N/P-well, and N+/P+, the Shallow Trench Isolations (STIs), and the ultrathin Buried-OXide (BOX) layers. SOTB technology is one of the Fully-Depleted Silicon-On-Insulator (FD-SOI) technology families with the key innovation of the ultrathin BOX layer. The layer that allows an appropriate back-gate bias voltage to be applied, thus increasing the control of transistors much more efficiently [28]. Furthermore, SOTB devices are good candidates for lowvoltage operation due to the low impurity concentration in the channel regions that leads to small variation [27]. By changing the back-gate bias voltage, the operation of the SOTB CMOS can be fine-tuned to satisfy either the lowpower or the high-performance requirements. To be specific, when the reverse back-gate bias voltage is applied, the leakage current can be reduced significantly. And when the forward back-gate bias voltage is deployed, the maximum operating frequency can be increased profoundly. Therefore, a SOTB microcontroller chip can be used for a wide range of embedded applications.



Fig. 2 Cross-section of the SOTB CMOS (modified from [28]).

3.2 Measurement result

The fabricated chips used 160-pin QFP packages. The PCB test boards with necessary accessories were built to test the chips. Fig. 3 shows a PCB platform with a chip inside the socket, a built-in USB-to-UART interface, programable

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Fig. 3 Test board (PCB) with the chip inside the socket.

clocks provided by a clock generator chip, and other peripherals such as SD-card socket, JTAG header, LEDs, and switches. The power supplies can be drawn directly from the USB interface or external power sources by using or not using the power jumpers. The operating clock also can be feed from an external source via the SMA connector.

The chip micrograph is given in Fig. 4. It can be seen that the four 16KB SRAM macros made up a total of 64KB on-chip memory for the system. The 16KB SRAM macro was chosen because it is the largest SRAM macro available in the 65-nm SOTB process. The 8KB of boot ROM also contains one 1KB SRAM macro for the stack. As shown in Fig. 4, there is one VexRiscv core placed in the bottom with two caches of instruction and data that sit right next to its left and right. Each cache contained four 1KB SRAM macros and one 512B SRAM macro, thus 4.5KB in total. The layout was 1,436.24- μ m in width and 921.6- μ m in height that sats on the 1.5×1.0-mm² die.

The main features of the chip are highlighted in Table I.



Fig. 4 The chip micrograph with floorplan.

Table I	Chin	features	summary

Technology	65-nm SOTB	
Layout size	$1,323,640 - \mu m^2 \approx 1.32 - mm^2$	
Gate-count	349,061	
I/O V _{DD}	3.3-V	
Core V _{DD}	0.5-V to 1.2-V	
Bonchmarks	1.27 DMIPS/MHz	
Dencinitai KS	2.4 Coremark/MHz	
Dool	at 1.2-V V_{DD} with +1.6-V V_{BB} :	
I tak	$F_{Max} = 156$ -MHz	
periormance	$P_{Active} = 269.54 \mu W/MHz$	
Bost nowor	at 0.5-V V_{DD} with +0.8-V V_{BB} :	
density	$F_{Max} = 15$ -MHz	
uchishty	$P_{Active} = 33.4 - \mu W/MHz$	
Best leakage	at 0.5-V V _{DD} with 0-V V _{BB} : $4.33-\mu$ A	
current	at 0.5-V V _{DD} with -2.0 -V V _{BB} : 3-nA	

The layout size was about 349,061 gate-counts on a 1.32-mm² of die area. The I/O V_{DD} was fixed at 3.3-V while the core V_{DD} can operate in the range of 0.5-V to 1.2-V. The processor achieved the benchmark results of 1.27 DMIPS/MHz and 2.4 Coremark/MHz. According to the table, at the high-performance operating mode, the chip can perform at 156-MHz with the highest V_{DD} and a forward V_{BB}. The best power density was 33.4- μ W/MHz with the lowest operating V_{DD}. At the sleep mode, the clock is cut off, and a reversed V_{BB} is applied; the lowest leakage current of 3-nA was achieved, as shown in the table.

Fig. 5 shows the changes in F_{Max} corresponding to V_{DD} and V_{BB} . Overall, the F_{Max} performances increased almost linear with the increment of V_{DD} . To be specific, with no bias (i.e., $V_{BB} = 0$ -V), F_{Max} values ranged from 12-MHz at 0.6-V V_{DD} to 104-MHz at 1.2-V V_{DD} ; the changes were about 15-MHz per 0.1-V of V_{DD} . For V_{BB} from -2.0-V to +0.8-V, F_{Max} values also increased nearly linear; there was about 18-MHz improvement in F_{Max} for each 0.4-V increment of V_{BB} . However, when a $V_{BB} \ge 1.2V$ was applied, the F_{Max} increment became very little to none, as seen in the figure. The maximum F_{Max} value of 156-MHz was achieved at 1.2-V V_{DD} with +1.6-V V_{BB} . At -2.0-V V_{BB} , the microcontroller can function only with $V_{DD} \ge 0.9$ -V.



Fig. 5 Maximum operating frequency (F_{Max}) vs. supply voltages.

Fig. 6 gives the variations in power consumption corresponding to V_{DD} and V_{BB} . Overall, the changes were

Table II Comparison with other 32-bit RISC-V microcontrollers.



Fig. 6 Operating power consumption (P_{active}) vs. supply voltages.

almost linear with the V_{DD} increment. For no bias, the power consumptions ranged from 40.8- μ W/MHz at 0.6-V V_{DD} to 169.04- μ W/MHz at 1.2-V V_{DD}; the changes were about 21- μ W/MHz for each 0.1-V increment of V_{DD}. At reversed back-gate bias, there were only tiny reductions in consumptions, as seen in the figure. In contrast, P_{Active} values increased quite a lot with forwarding back-gate bias. Comparing to the no bias power consumption line, the +2.0-V V_{BB} power consumption line was about 1.86× higher at all range of V_{DD}. The best power density of 33.4- μ W/MHz was achieved at the lowest operating point of 0.5-V V_{DD} with +0.8-V V_{BB}.

Fig. 7 shows the changes in leakage current corresponding to V_{DD} and V_{BB} . The leakage current values were measured at sleep mode when the clock is cut off. At no bias, I_{leak} values ranged from 4.33- μ A at 0.5-V V_{DD} to 25- μ A at 1.2-V V_{DD} . From +0.8-V to -1.2-V V_{BB} , the I_{leak} values reduced roughly about one order of magnitude per 0.4-V V_{BB} reduction. However, the $V_{BB} \leq -1.6$ -V lines can not result in further reduction of leakage currents due to the Gate-Induced Drain Leakage (GIDL) phenomenon [28]. The best leakge current was 3-nA with 0.5-V V_{DD} and -2.0-V V_{BB} .



Fig. 7 Leakage current (Ileak) vs. supply voltages.

3.3 Comparison and discussion

For the comparison, Table II gives the results of this work and two other recent 32-bit RISC-V microcontrollers. To provide a better point-of-view, the results of PULPv2 [21] and Duran *et al.* [23] were scaled to the equivalent results of a 65-nm node by using the equations from [30]. It is noted that

Design	Duran et al.	PULPv2	This work
	(2017) [23]	(2017) [21]	(2020)
ISA	RV32IM	RV32IMC	RV32IM
No. of cores	1	4	1
Core V _{DD} (V)	1.2	032 to 1.15	0.5 to 1.2
Process	130-nm	28-nm	65-nm
F _{Max} (MHz)	160	825	156
P _{Active} (µW/MHz)	167	20.7	33.4
Leakage power (mW) *			
running	N/A	0.37	0.4
idle (clock-gated)	N/A	N/A	0.003
Scaled to 65-nm by using equations [30]			
Process	65-nm	65-nm	65-nm
F _{Max} (MHz)	304.88	388.68	156
P _{Active} (µW/MHz)	23.05	126.6	33.4
Leakage power (mW) *			
running	N/A	2.22	0.4
idle (clock-gated)	N/A	N/A	0.003
* measured at 0.6-V Vpp & no hias			

measured at 0.6-V V_{DD} & no bias.

because the equations in [30] did not have the parameters for the 28-nm process, the scaled values of PULPv2 [21] were calculated by using the settings of the 32-nm process instead.

Although the F_{Max} in this work is the lowest value in the table, the comparison may not reflect the true nature of the architecture. The reason is that for those designs without integrated Phase-Locked Loop (PLL) or Frequency-Locked Loop (FLL), the operating frequencies heavily depended on the I/O circuits. For example, the chip in [21] had integrated FLL while those chips in [23] and in this work had not. Therefore, the operating frequency in [21] could easily go higher than 500-MHz, while those in [23] and in this work were limited by the general digital I/Os, as seen in the table.

For the dynamic power consumption of P_{Active} , the result of this work was measured while running the Dhrystone test, while the result in [23] was measured while running three while loops. Therefore, if the microcontroller in [23] was running the Dhrystone test when being measured, the value of 23.05- μ W/MHz should be a bit higher. For the result of [21], it can be argued that if with a single-core processor, its power consumption will be much less. Hence, the power density of a single-core of PULPv2 can be roughly approximated by 126.6/4 = 31.65- μ W/MHz, closes to the value of 33.4- μ W/MHz of this work.

For leakage power comparison, the PULPv2 chip [21] reported 0.37-mW while running at 0.6-V V_{DD} with no bias (i.e., $V_{BB} = 0$ -V). Scaling to the equivalent result of the 65-nm node, 0.37-mW became 2.22-mW. With a similar argument about single-core versus multi-core, the leakage power of a single-core could be roughly estimated to about 2.22/4 = 0.555-mW. Thus, the 0.4-mW result of this work still yields the best performance in the table. It is also noted that the best values of leakage powers in this work were not brought to the comparison table because the results with reserved back-gate bias voltages were not reported in those papers [21, 23]. Furthermore, the results at sleep-mode with

the applied clock-gating technique were also not presented in the papers [21, 23]. For this work, the leakage power with clock-gating reduced nearly $133.33 \times$ to $3-\mu$ W compared to the without clock-gating result at the same operating condition.

To conclude, a truly fair comparison between implementations were hard to achieve due to the complex nature of microcontroller architecture. Table II has already brought a proper perspective for the comparison, but yet, it may not ultimately reflect all of the pros and cons of all implementations. However, it can be said that the proposed microcontroller chip in this paper has achieved average performances of F_{Max} and P_{Active} and a genuinely good leakage power value. With the powerful tool of back-gate biasing, the proposed microcontroller can be used for a wide range of embedded applications in both means of low-power and high-performance settings.

4. Conclusion

The 32-bit RISC-V microcontroller based on RV32IM VexRiscv CPU was presented in this paper. The completed system-on-chip was built and fabricated with the 65-nm SOTB technology. Its measurement results were presented and discussed with other recent silicon-proof publications. The proposed SoC was benchmarked by using the Dhrystone and Coremark tests, and the results were 1.27 DMIPS/MHz and 2.4 Coremark/MHz, respectively. The layout occupied 1.32-mm² of die area with 349,061 gate-counts. The core V_{DD} range is 0.5-V to 1.2V, and the core back-gate bias voltage range is -2.0-V to +2.0-V. The measurement results show the highest operating frequency was 156-MHz, the lowest operating V_{DD} was 0.5-V, the best power density was 33.4- μ W/MHz, and the best current leakage was 3-nA. The SOTB technology gave not only the astonishing ultralow-power characteristic but also the flexibility of operating modes. As a result, with back-gate bias voltage control, the proposed implementation can be suited for a wide range of embedded applications nowadays in both needs of lowpower or high-performance microcontroller systems.

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